First demonstration of single-layer InAs/InP (100) quantum-dot laser: continuous wave, room temperature, ground state

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First description of single-layer InAs/InP (100) quantum-dot laser: continuous wave, room temperature, ground state


Reported is the first InAs/InP (100) quantum-dot (QD) laser operating in continuous-wave mode at room temperature on the QD ground state transition employing a single-layer of QDs grown by metal organic vapour phase epitaxy. The necessary high QD density is achieved by growing the QDs on a thin InAs quantum well (QW). These QDs on the QW laser exhibit a high slope efficiency and a lasing wavelength of 1.74 μm, which is important for biomedical applications.

Introduction: InAs/InP (100) quantum-dot (QD) lasers operating in continuous-wave (CW) mode at room temperature (RT) on the QD ground state (GS) transition have been reported, mostly for applications in the 1.55 μm telecom wavelength region. These lasers required multiple stacked QD layers for sufficient gain [1, 2]. A single-layer InAs QD laser was reported on InP (311)B where the QD density is higher than on InP (100) [3]. In this Letter, we report the first single-layer InAs/InP (100) QD laser operating in CW mode at RT on the QD GS transition. The necessary high QD density is achieved by growing the QDs on a thin InAs quantum well (QW). These single-layer InAs QDs on a QW laser exhibit a higher slope efficiency compared to that of the lasers with multiple stacked conventional QDs. The lasing wavelength is 1.74 μm. This longer wavelength is technologically important for, e.g., gas sensing and biomedical applications [4].

Device fabrication: The QD lasers were grown by low-pressure metal organic vapour phase epitaxy (MOVPE) on InP (100) substrates using trimethyl-indium (TMI), trimethyl-gallium (TMG), tertiarybutylarsine (TBA), and tertiarybutyl-phosphine (TBP) as gas sources. The InAs QDs on QW structures and conventional InAs QDs for reference were placed in the centre of a 500 nm-thick lattice-matched InGaAsP waveguide core with a bandgap at λo = 1.25 μm (Q1.25). For the InAs QDs on the QW structure, the InAs QW was formed under metal stable conditions. [5]. Only TMI was first supplied to an equivalent of 0.56 monolayer (ML) InAs, followed by 0.70 ML InAs. This sequence was repeated to a total thickness of 1.6 nm InAs. The QDs on top of the QW were grown by switching to normal growth condition with continuous TBA supply. One ML InAs was deposited for QD formation, which is already sufficient to obtain a large amount of surface segregated In on the InAs QW. The conventional InAs QDs (single and multiple stacked layers separated by 40 nm Q1.25) were formed by 3 ML InAs on a 1.5 ML GaAs interlayer. The GaAs interlayer allows the formation of pure InAs QDs on Q layers with small diameter owing to suppression of As/P exchange [6]. The InAs QW grows rate and growth temperature were 0.70 ML/s and 515 °C, and the TBA flow rate was 30 scm, which shifts also the lasing wavelength of the conventional QD lasers to around 1.75 μm. Bottom and top claddings of the laser structures were 500 nm InP and 1.5 μm p-InP completed by a compositionally graded 75 nm p-InGaAsP contact layer. 2 μm narrow ridge waveguide lasers were fabricated with cavity lengths of 2 mm and uncoated cleaved facets.

Fig. 1 AFM images of InAs QDs
a Grown on 1.6 nm-thick InAs QW
b Grown on InGaAsP with 1 ML GaAs interlayer
Height contrast is 40 nm

Results: Figs. 1a and b show the atomic force microscopy (AFM) images of the InAs QDs grown on the 1.6 nm InAs QW and on Q1.25. The QD density is increased five to six times in the presence of the InAs QW from 6 x 10^10 cm^-2 for the QD grown on Q1.25 to 3.4 x 10^11 cm^-2. The QD size is comparable. This increase of the QD density on the InAs QW is attributed to the large amount of strain and surface segregated In after QW growth.

Figs. 2a-c show the electroluminescence and lasing spectra of the single-layer InAs QDs on QW laser and the fivefold and threefold stacked InAs QDs lasers taken in CW mode at RT. QD GS lasing is obtained for the single-layer InAs QDs on the QW laser with lasing wavelength of 1.74 μm and for the fivefold stacked InAs QD laser. Excited state (ES) lasing of the single-layer InAs QDs on the QW laser sets in with increasing injection current, confirming GS lasing at threshold, shown in Fig. 2a at twice the threshold current (Ith). For the threefold stacked InAs QD laser only lasing from the ES, which provides higher gain owing to the threefold degeneracy, is observed at 1.68 μm owing to the lower QD GS gain. For the single layer of InAs QDs lasing is not observed.

Fig. 2 Electroeluminescence and lasing spectra of single-layer InAs QDs on QW laser and fivefold and threefold stacked InAs QD lasers for injection currents of 0.9 Ith, 1.1 Ith and 2 Ith
a Single-layer InAs QDs on QW laser
b,c Fivefold and threefold stacked InAs QD laser

Fig. 3 Light output against injection current curves of single-layer InAs QDs on QW laser and fivefold and threefold stacked InAs QD lasers
Cavity length (L) and width of ridge waveguide (W) are 2 mm and 2 μm

Fig. 3 shows the single facet light output against injection current curves of the three QD lasers. Ith and the threshold current density (Jth) of the single-layer InAs QDs on the QW laser are 110 mA and 2.75 kA/cm^2. The fivefold stacked InAs QD laser reveals Ith = 92 mA and a Jth of 0.46 kA/cm^2 per QD layer. For the threefold stacked InAs QD laser Ith = 116 mA and Jth per QD layer is increased significantly to 0.97 kA/cm^2 owing to the threefold degeneracy of the ES. The threshold current of the single-layer InAs QDs on the QW laser is slightly larger than that of the fivefold stacked InAs QD laser.
both lasing on the QD GS, but the slope efficiency is larger. This is attained by the high density QDs on the QW, the larger confinement factor for the single-layer QDs on the QW in the centre of the waveguide, and better carrier injection into this single layer.

Conclusions: We have successfully achieved lasing in CW mode at RT on the QD GS transition of single-layer InAs QDs on a QW structure grown by MOVPE on InP (100) substrates. This is enabled by the five to six times increased QD density on the InAs QW compared to that of conventional QDs. The single-layer QDs on the QW laser exhibit a higher slope efficiency compared to that of multiple stacked InAs QD lasers. The lasing wavelength is 1.74 μm, which is of interest for gas sensing and biomedical applications.

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